

BJT

① 放大电路概述

* 静态分析：直流通路求静态工作点 Q : U_{BE} , I_B , I_C , U_{CE}

其中：硅管 $|U_{BE}| = 0.7V$, 锗管 $|U_{BE}| = 0.3V$

* 动态分析：交流通路求动态性能指标： A_u , R_i , R_o

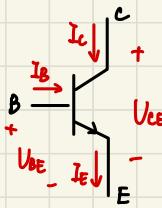
+ 微变等效电路模型

U_{BE} 发射极与基极电压

I_B 基极电流

I_C 集电极电流

U_{CE} 管压降

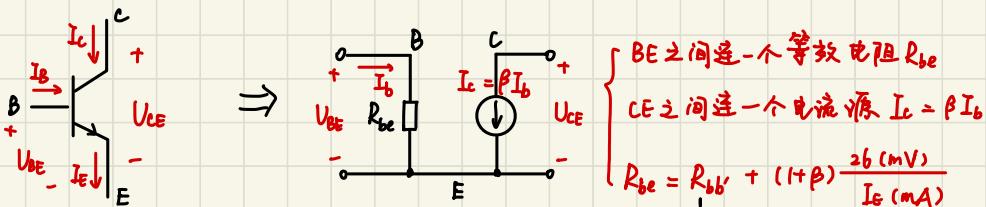


$$A_u \text{ 放大倍数} \leftarrow \frac{U_o}{U_i}$$

$$R_i \text{ 输入电阻} \leftarrow \frac{U_i}{I_i}$$

$$R_o \text{ 输出电阻} \leftarrow \text{去源, } R_C \text{ 开路, } = \frac{U_o}{I_o}$$

② 微变等效电路模型



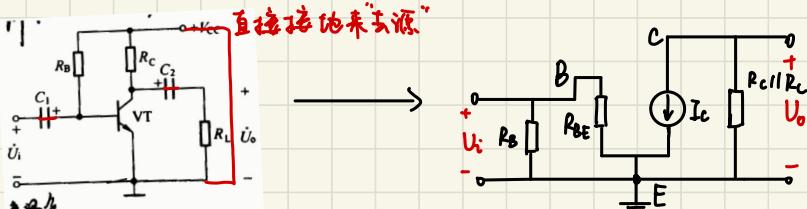
③ 当三极管在放大区时

$$\begin{cases} I_C = \beta I_B \\ I_E = (1+\beta) I_B \\ I_E = I_B + I_C \end{cases}$$

基区体电阻（题目会
给 $R_{bb'}$ ）

④ 画微变等效电路

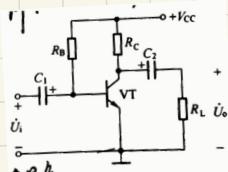
电容看做短路，直流电源作“去源”处理。擦去三极管并用等效电路替换



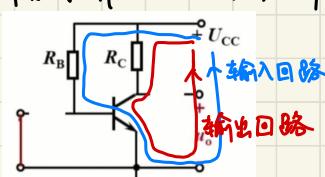
⑤ BJT 双极型三极管的共射放大电路

共射电路：基电极 B 输入，集电极 C 输出

总电路图：



静态工作点求解：(支流短接, C断路)



Step 1 求 I_B : $I_B R_B + U_{BE} - U_{CC} = 0$

Step 2 求 I_C : $I_C = \beta I_B$

Step 3 求 U_{CE} : $I_C R_C + U_{CE} - U_{CC} = 0$

输入电压 V_{GS} 会由直流的 V_{G_S} 和交流的 v_{GS} 组成 ($V_{GS} = V_{G_S} + v_{GS}$)

$$I_{eff} = I_{drain} - 2L_P$$

对于直流部分，我们可以用直流通路来求出 $I_D = \begin{cases} \text{若 } V_{DS} > V_{DS} - V_{TH} \text{ 不考虑 channel-length modulation} \\ \text{若 } V_{DS} \leq V_{DS} - V_{TH} \text{ 考虑 channel-length modulation} \end{cases}$

对于 I_D ：① 不饱和 (triode region) $\rightarrow V_{GS} - V_{TH} > V_{DS} > 0$

$$I_D = \mu_n C_{ox} \left(\frac{W}{L_{eff}} \right) [(V_{GS} - V_{TH}) V_{DS} - \frac{1}{2} V_{DS}^2]$$

② 饱和并且考虑 channel-length modulation

$$I_D = \frac{1}{2} \mu_n C_{ox} \left(\frac{W}{L_{eff}} \right) (V_{GS} - V_{TH})^2 (1 + \lambda V_{DS}) \Rightarrow I_D = \frac{1}{2} \mu_n C_{ox} \left(\frac{W}{L_{eff} - \Delta L} \right) (V_{GS} - V_{TH})^2$$

③ 饱和但不考虑 channel-length modulation

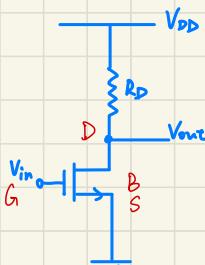
$$I_D = \frac{1}{2} \mu_n C_{ox} \left(\frac{W}{L_{eff}} \right) (V_{GS} - V_{TH})^2$$

求完 I_D 之后才能进 small signal 分析：

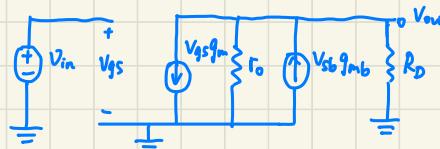
$$g_m = \begin{cases} \frac{2I_D}{V_{GS} - V_{TH}} = \sqrt{2\mu_n C_{ox} \frac{W}{L_{eff} - \Delta L} I_D} = \mu_n C_{ox} \frac{W}{L_{eff} - \Delta L} (V_{GS} - V_{TH}) & \text{不考虑 channel} \\ \sqrt{2\mu_n C_{ox} \left(\frac{W}{L_{eff} - \Delta L} \right) I_D (1 + \lambda V_{DS})} = \mu_n C_{ox} \frac{W}{L_{eff} - \Delta L} (V_{GS} - V_{TH}) (1 + \lambda V_{DS}) & \text{考虑 channel} \end{cases}$$

$$r_o = \begin{cases} 0 & \text{不考虑 channel} \\ \frac{1}{\frac{1}{2} \mu_n C_{ox} \frac{W}{L_{eff} - \Delta L} (V_{GS} - V_{TH})^2 \cdot \lambda} = \frac{1}{I_D \cdot \lambda} & \text{考虑 channel} \end{cases}$$

$$g_{mb} = \begin{cases} 0 & \text{不考虑 body effect} \\ g_m \cdot \frac{\gamma}{2\sqrt{2\phi_F + V_{SB}}} = \gamma g_m & \text{考虑 body effect} \end{cases}$$



微变电路

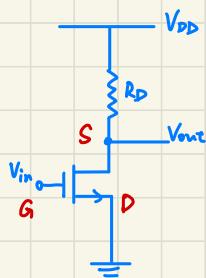


Gate: 棚极

Source: 源极

Drain: 漏极

(ps: PMOS 公式加绝对值就行)



PMOS Formula Table

NMOS Transistor Mathematical Model Summary

The following equations represent the complete model for the $i - v$ behavior of the NMOS transistor.

For all regions,

$$K_p = K'_p \frac{W}{L} \quad K'_p = \mu_p C_{ox}'' \quad i_G = 0 \quad i_B = 0 \quad (15)$$

Cut off region,

$$i_D = 0 \quad \text{for } V_{GS} \geq V_{TP} \quad (16)$$

Triode region,

$$i_D = K_p \left(v_{GS} - V_{TP} - \frac{v_{DS}}{2} \right) v_{DS} \quad \text{for } 0 \leq |v_{DS}| \leq |v_{GS} - V_{TP}| \quad (17)$$



PMOS Formula Table



Saturation region,

$$i_D = \frac{K_p}{2} (v_{GS} - V_{TP})^2 (1 + \lambda |v_{DS}|) \quad \text{for } |v_{DS}| \geq |v_{GS} - V_{TP}| \geq 0 \quad (18)$$

Threshold voltage,

$$V_{TP} = V_{TO} + \gamma (\sqrt{v_{SB} + 2\phi_F} - \sqrt{2\phi_F}) \quad (19)$$

For the enhancement-mode PMOS transistor, $V_{TP} < 0$. Depletion-mode PMOS devices can also be fabricated; $V_{TP} \geq 0$ for these devices.

Body effect (体效应), 也称作**substrate effect (底座效应)**, 是指在MOSFET (金属氧化物半导体场效应晶体管) 中, 由于栅极和底座 (substrate) 之间的电压差异, 导致晶体管特性发生变化的现象。

MOSFET是由P型或N型的底座 (衬底) 和两个与之电性相反的源极 (Source) 和漏极 (Drain) 组成。栅极 (Gate) 位于底座上, 通过控制栅极电压可以控制源极和漏极之间的电流。在MOSFET中, 底座与源极之间的电压差会影响晶体管的工作特性, 这就是体效应。

具体来说, 当在MOSFET的底座与源极之间施加反向偏置 (对于N型MOSFET是正向偏置), 底座的电势会影响通道区域的形成, 从而影响源极和漏极之间的电流。这是因为底座与通道之间的电势差会改变通道中的载流子浓度。底座与源极电压之间的这种关系可以通过

MOSFET的参数之一, 称为阈值电压 (Threshold Voltage), 来表示。

在集成电路设计和应用中, 需要考虑体效应, 尤其是在高度集成的CMOS电路中。通过了解体效应的影响, 工程师可以更好地优化MOSFET的特性, 以确保电路的性能和可靠性。

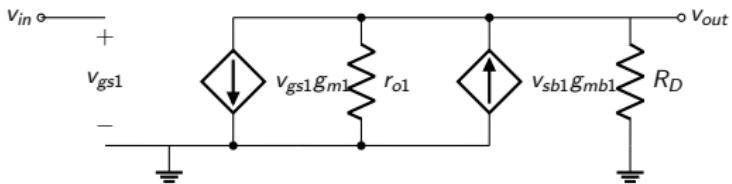
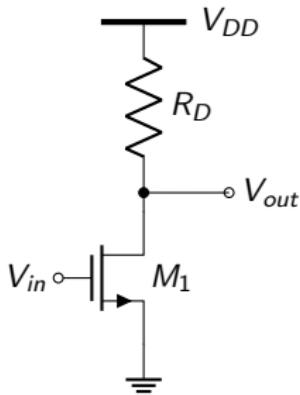
Channel-Length Modulation (沟道长度调制)是指在MOSFET (金属氧化物半导体场效应晶体管) 中, 当沟道长度发生变化时, 晶体管的特性也会相应地改变的现象。

MOSFET的沟道长度指的是源极和漏极之间形成的通道区域的长度。当MOSFET处于饱和区 (Saturation Region) 时, 沟道长度的变化会导致漏极电流 (ID) 发生调制, 即漏极电流与漏极电压 (VDS) 之间的关系不再是简单的线性关系。

具体来说, 当VDS增大时, 沟道长度会因为底座与源极之间的电场而增加。由于沟道长度的增加, 通道中的电荷载流子数量增多, 从而导致漏极电流ID增加。这种现象就是沟道长度调制。

在高电压或高电流的工作条件下, 沟道长度调制会成为一个显著影响MOSFET工作的因素。这可能导致MOSFET的输出电流不再是一个固定的值, 而是与VDS有关。为了准确建模和设计MOSFET电路, 工程师需要考虑沟道长度调制效应, 特别是在高性能和高精度的电路应用中。

CS with Resistive Load



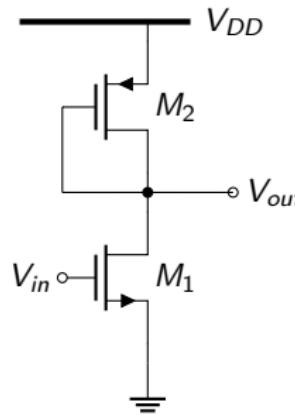
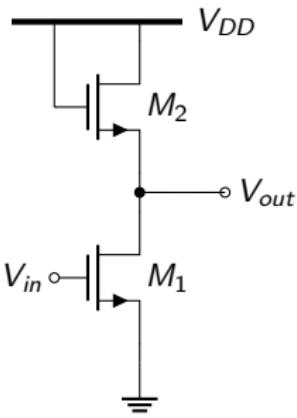
If no channel-length and body effect:

$$A_v = \frac{v_{out}}{v_{in}} = -g_{m1}R_D \quad (1)$$

No body effect:

$$A_v = -g_{m1}(R_D \parallel r_{o1}) \quad (2)$$

CS with Diode-connected Load



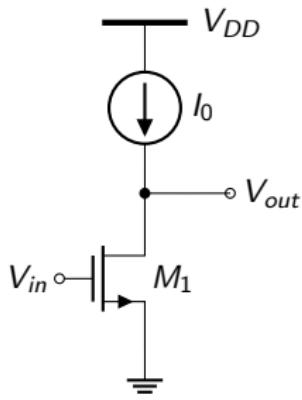
NMOS:

$$A_v = -\sqrt{\frac{(W/L)_1}{(W/L)_2}} \frac{1}{1 + \eta} \quad \eta = g_{mb2}/g_{m2} \quad (3)$$

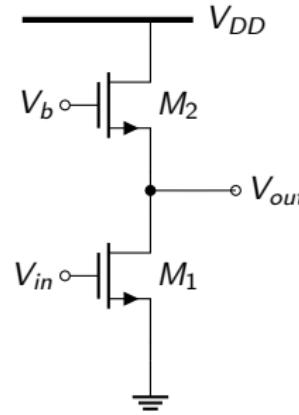
PMOS:

$$A_v = -\sqrt{\frac{\mu_n(W/L)_1}{\mu_p(W/L)_2}} \quad (4)$$

CS with Current Source Load

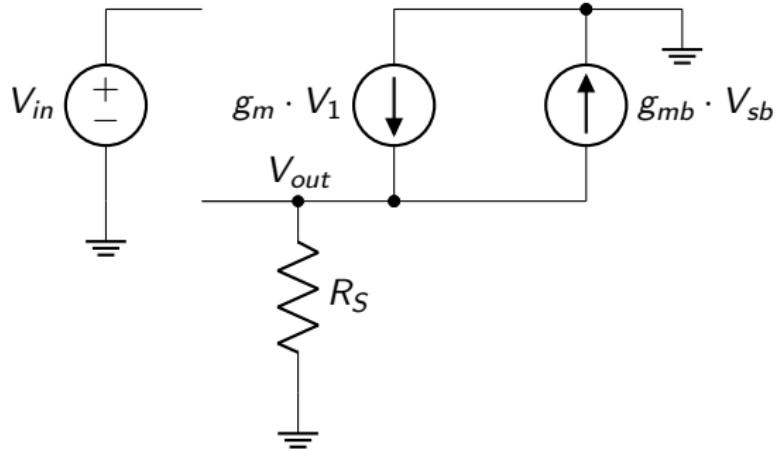
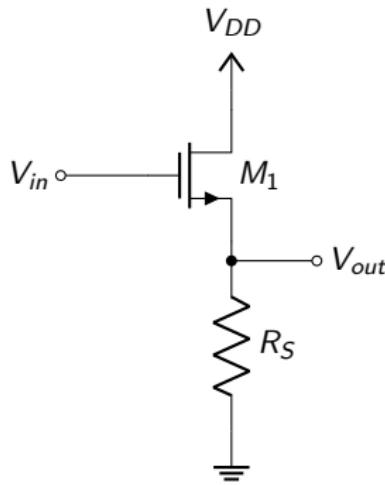


or



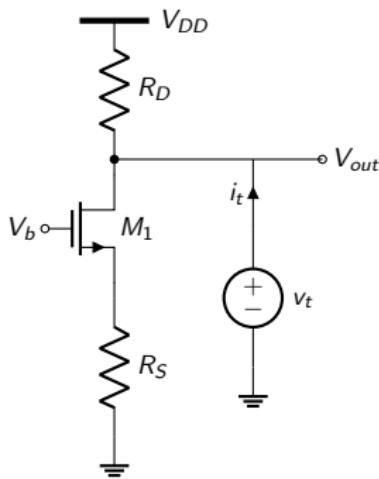
$$A_v = -g_{m1}(r_{o2} \parallel r_{o1}) \quad (5)$$

Source Follower

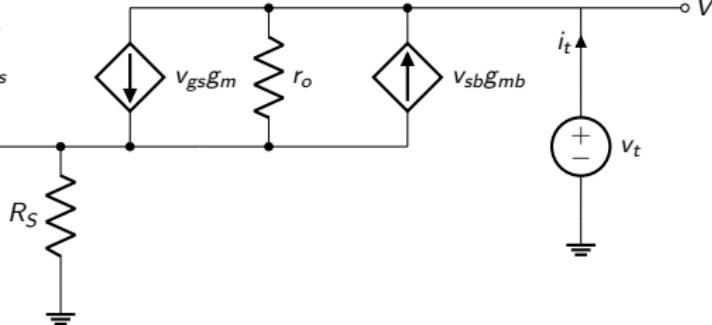


$$A_v = \frac{g_m R_S}{1 + g_m R_S(1 + \eta)} = \frac{g_m R_S}{1 + (g_m + g_{mb})R_S} \approx \frac{1}{1 + \eta} \quad (6)$$

Common Gate



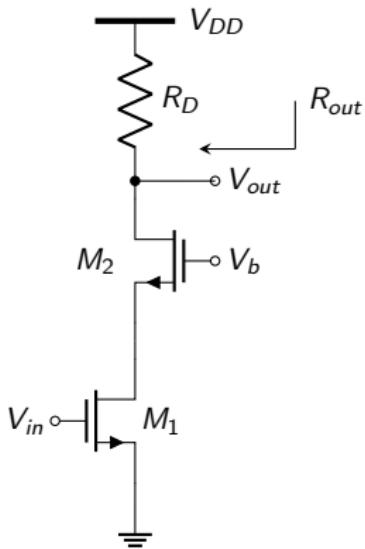
v_{in} o — +
— v_{gs}



$$R_{in} = \frac{R_D + r_o}{1 + (g_m + g_{mb})r_o} \begin{cases} \text{If } R_D = 0 & R_{in} = r_o \parallel \frac{1}{g_m} \parallel \frac{1}{g_{mb}} \\ \text{If } R_D = \infty & R_{in} = \infty \end{cases} \quad (7)$$

$$R_{out} = [R_S + r_{o1} + (g_{m1} + g_{mb1})r_{o1}R_S] \parallel R_D \quad (8)$$

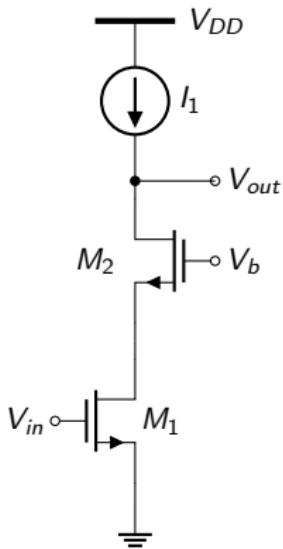
Cascode



$$G_m = -g_{m1} \frac{r_{o1}}{r_{o1} + \left(r_{o2} \parallel \frac{1}{g_{m2} + g_{mb2}} \right)} \quad (9)$$

$$R_{out} = [r_{o1} + r_{o2} + (g_{m2} + g_{mb2})r_{o2}r_{o1}] \parallel R_D \quad (10)$$

Cascode

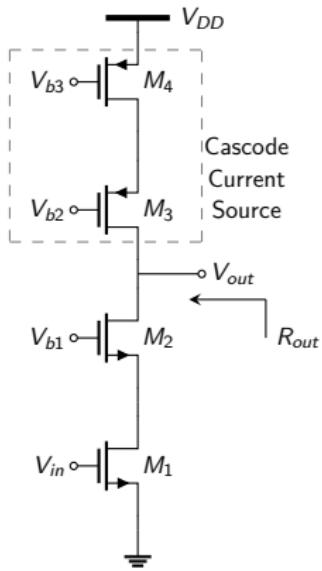


$$G_m = -g_{m1} \frac{r_{o1}}{r_{o1} + \left(r_{o2} \parallel \frac{1}{g_{m2} + g_{mb2}} \right)} \quad (11)$$

$$R_{out} = r_{o1} + r_{o2} + (g_{m2} + g_{mb2})r_{o2}r_{o1} \quad (12)$$

$$A_v = G_m R_{out} \quad (13)$$

Cascode

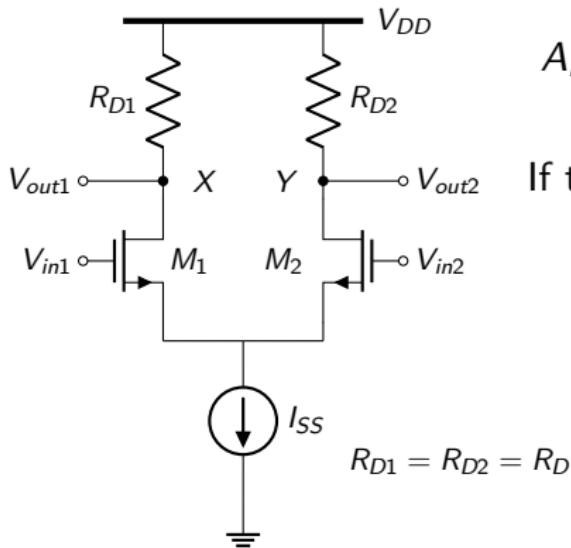


$$G_m = -g_{m1} \frac{r_{o1}}{r_{o1} + (r_{o2} \parallel \frac{1}{g_{m2}g_{mb2}})} \quad (14)$$

$$R_{out} = [r_{o1} + r_{o2} + (g_{m2} + g_{mb2})r_{o2}r_{o1}] \\ \parallel [r_{o3} + r_{o4} + (g_{m3} + g_{mb3})r_{o3}r_{o4}] \quad (15)$$

$$A_v = G_m R_{out} \quad (16)$$

Differential Pair



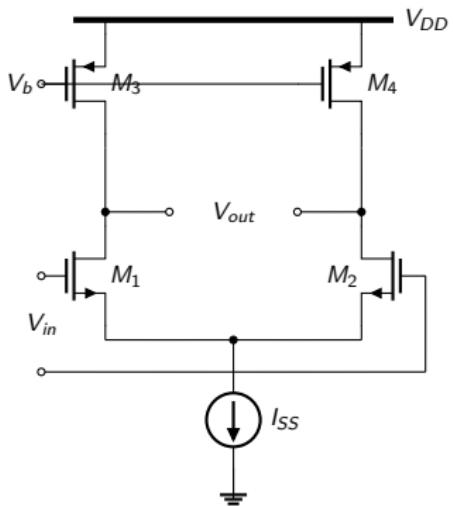
$$A_{DM} = \frac{V_{out1} - V_{out2}}{v_d} = -g_m(R_D \parallel r_o) \quad (17)$$

If the circuit is fully symmetric,

$$A_{CM-DM} = \frac{V_{out1} - V_{out2}}{v_{in,CM}} = 0 \quad (18)$$

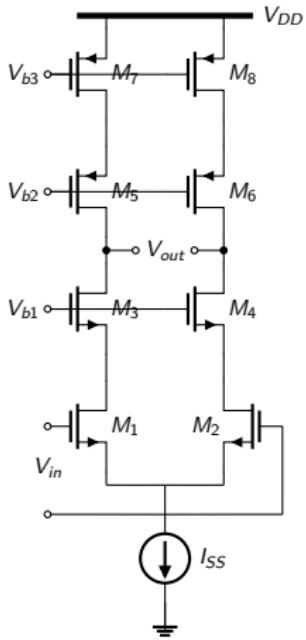
$$CMRR = \left| \frac{A_{DM}}{A_{CM-DM}} \right| = \infty \quad (19)$$

Differential Pair with MOS Loads



$$A_{DM} = -g_{m1,2}(r_{o1,2} \parallel r_{o3,4}) \quad (20)$$

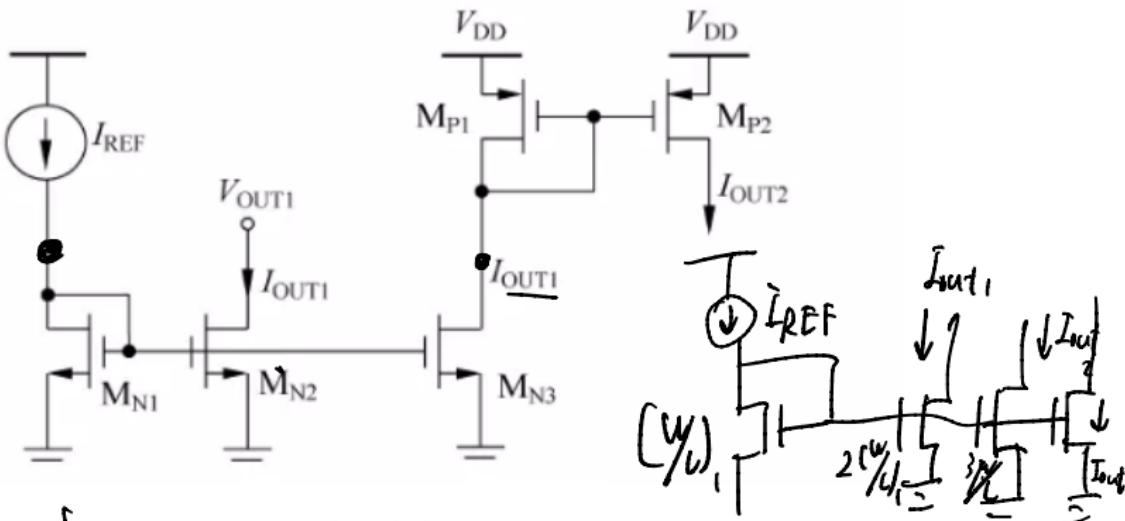
Differential Pair with Cascode Loads



$$A_{DM} \cong -g_{m1,2} [(g_{m3,4} + g_{mb3,4})r_{o3,4}r_{o1,2} \parallel (g_{m5,6} + g_{mb5,6})r_{o5,6}r_{o7,8}] \quad (21)$$

Current Mirror

at most 4 MOSFET



$$I_{\text{OUT1}} = \frac{(W/L)_{N2}}{(W/L)_{N1}} I_{\text{REF}}$$

$$I_{\text{OUT2}} = \frac{(W/L)_{N3}}{(W/L)_{N1}} \frac{(W/L)_{P2}}{(W/L)_{P1}} I_{\text{REF}}$$

$$I_{out1} = 2 I_{REF}$$

$$I_{out2} = 3I_{REF}$$

Bode 图绘制

⇒ 低频部分会过 $(1, 20 \lg k)$ → 此处 $(1, 20 \log 25)$

① 化成标准形式：

$$\text{如 } H(s) = \frac{25(0.1s+1)}{s^2(0.2s+1)}$$

此时有比例环节(1个) : 25

积分环节(2个) : $\frac{1}{s^2}$

导前环节(1个) : $0.1s+1$

惯性环节(1个) : $0.2s+1$

比例环节: $G(s) = k$

积分环节: $G(s) = \frac{1}{s}$

微分环节: $G(s) = s$

惯性环节: $G(s) = \frac{1}{Ts+1}$

导前环节: $G(s) = Ts+1$

确定了
第一条
线

II型系统(有几个积分环节就是几型系统)



$V=2 \Rightarrow \text{低频部分斜率为 } -20 \text{ dB/dec} \cdot V = -40 \text{ dB/dec}$



② 求频率特性(把 s 变为 jw)

$$H(jw) = \frac{25(j0.1w+1)}{(jw)^2(j0.2w+1)}$$

{ 对导前环节 $j0.1w+1$, $w_2 = \frac{1}{0.1} = 10 \text{ s}^{-1}$ (小的标)

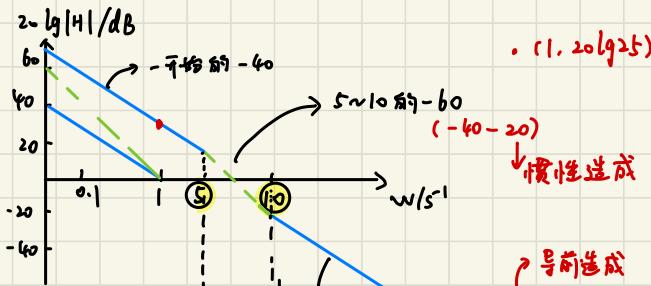
{ 对惯性环节 $j0.2w+1$, $w_1 = \frac{1}{0.2} = 5 \text{ s}^{-1}$

{ 对导前环节 w_2 开始斜率上升 20 dB/dec

{ 对惯性环节 w_2 开始斜率下降 -20 dB/dec

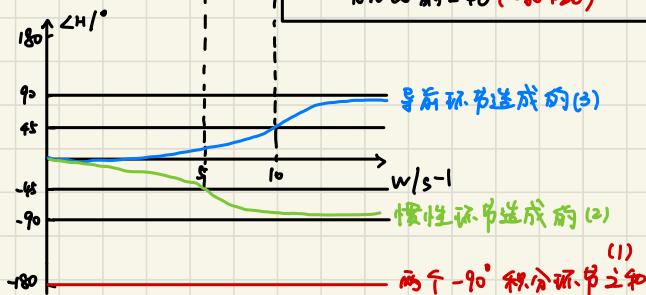
③ 画图

幅频图 →

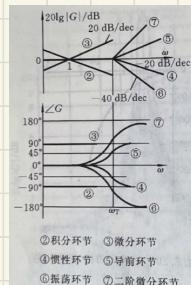


相频图 →

把(1)(2)(3)加起来
即可得到结果



不含比例环节

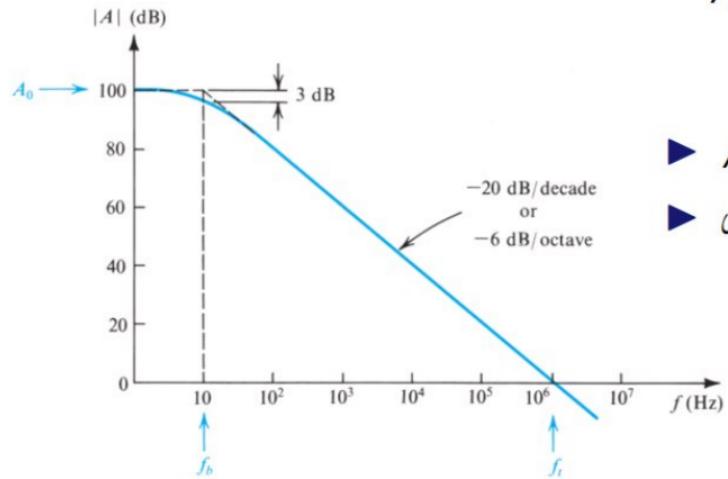


Pole-zero representation

- ▶ Bode plot (magnitude)
 - ▶ Zero contributes 20dB/decade slope if $s > s_z$
 - ▶ Pole contributes -20dB/decade slope if $s > s_p$
 - ▶ Complex conjugate zeros contributes 40dB/decade slope if $s > |s_z|$
 - ▶ Complex conjugate poles contributes -40dB/decade slope if $s > |s_p|$
- ▶ Bode plot (phase)
 - ▶ 90° if $s_z = 0$
 - ▶ -90° if $s_p = 0$
 - ▶ Increase by 90° and passes through the midpoint of 45° at the break point $s = s_z \neq 0$
 - ▶ Decrease by 90° and passes through the midpoint of -45° at the break point $s = s_p \neq 0$

Finite op amp bandwidth

$$A(j\omega) = \frac{A_0}{1 + j\omega/\omega_b} \quad (8)$$



- ▶ A_0 : dc gain
- ▶ ω_b : 3-dB frequency

Finite op amp bandwidth

- ▶ Magnitude:

$$| A(j\omega) | = \frac{A_0 \omega_b}{\omega} \quad (9)$$

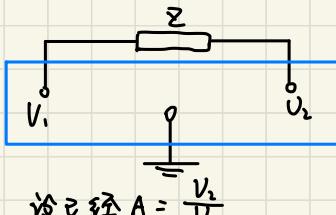
- ▶ Unity gain:

$$A(j\omega_t) = 1 \quad (10)$$

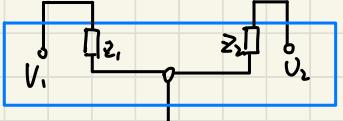
- ▶ unity-gain bandwidth (gain-bandwidth product)

$$f_t = \frac{\omega_t}{2\pi} = \frac{A_0 \omega_b}{2\pi} \quad (11)$$

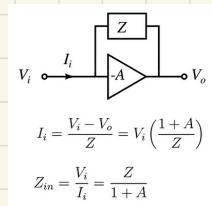
Miller Effect:



\Leftrightarrow



$$Z_1 = \frac{Z}{1-A}, \quad Z_2 = \frac{Z}{1-\frac{1}{A}}$$



Example 1



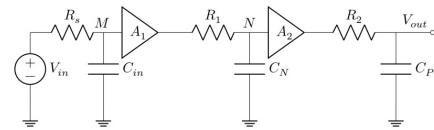
Association of Poles with Nodes



$$A_v = \frac{Y}{X} = 1 + (g_{m1} + g_{mb1}) r_{o1} \quad (4)$$

$$Z_1 = \frac{r_{o1}}{1 - [1 + (g_{m1} + g_{mb1}) r_{o1}]} = \frac{-1}{g_{m1} + g_{mb1}} \quad (5)$$

$$R_{in} = \frac{-1}{g_{m1} + g_{mb1}} \parallel \frac{1}{g_{m1} + g_{mb1}} = \infty \quad (6)$$



$$\frac{V_{out}}{V_{in}}(\omega) = A_1 A_2 \frac{1}{\left(1 + \frac{s}{\omega_M}\right) \left(1 + \frac{s}{\omega_N}\right) \left(1 + \frac{s}{\omega_P}\right)} \quad (8)$$

$$\omega_M = \frac{1}{R_S C_{in}} \quad (9) \quad \omega_N = \frac{1}{R_1 C_N} \quad (10) \quad \omega_P = \frac{1}{R_2 C_P} \text{ (rad/s)} \quad (11)$$

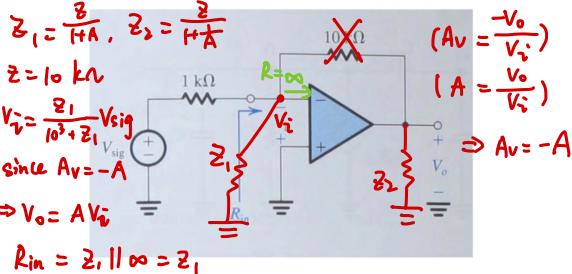
Example 2



Exercise 1



Assume the op amp to be ideal except for having a finite differential gain A and $V_{sig} = 1V$. Use Miller's theorem to find R_{in}, V_i, V_o for each of the following values of A : 10, 100, 1000 (without using knowledge of op-amp circuit analysis)



$$H(s) = \frac{H^0 + H^1 \tau s}{1 + \tau s} \quad (15)$$

- Time constant: (1) For capacitor: $\tau = RC$; (2) For inductor: $\tau = \frac{L}{R}$
- To find the time constant, remove the cap/ind nulling all the sources and find the resistance.
- To find H^0 , use low frequency gain(cap cut off and ind shorted).
- To find H^1 , use high frequency gain(cap shorted and ind cut off).

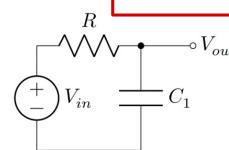
$H_0:$ $\Rightarrow V_{out} = 0 \Rightarrow \frac{V_{out}}{V_{in}} = 0$

$$H^0 = 1 \quad (16)$$

$$\tau = RC_1 \quad (17)$$

$$H^1 = 0 \quad (18)$$

$$H(s) = \frac{1}{1 + RCS} \quad (19)$$



$H_1:$

V_{in} $\Rightarrow \frac{V_{out}}{V_{in}} = 1$

$H_2:$ $\Rightarrow \tau = \frac{V_t}{V_t} C_1 = RC_1$

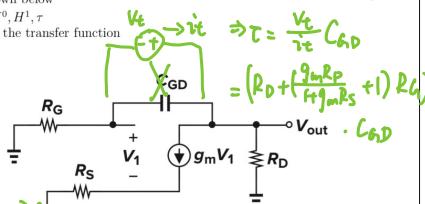
Exercise 2



$$\textcircled{1} H_0: g_m V_1 R_S = V_t - V_{in}$$

For the circuit shown below

- (a) Calculate H^0, H^1, τ
(b) Write down the transfer function



$$\textcircled{2} H^1: (\text{Cap短})$$

$$\begin{aligned} V_{in} + R_S g_m V_1 &= V_{out} - V_1 \\ \frac{V_{out}}{R_D} + \frac{V_{out}}{(R_S + g_m V_1)} &= 0 \end{aligned} \Rightarrow H^1 = \frac{1}{1 + (R_S + \frac{1}{g_m V_1})(\frac{1}{R_D} + \frac{1}{R_S})}$$

Nth Order Systems



$$H(s) = \frac{a_0 + a_1 s + a_2 s^2}{1 + b_1 s + b_2 s^2} \quad (25)$$

$$b_1 = \sum_{i=1}^N \tau_i^0 \quad (26)$$

$$b_2 = \sum_{i=1}^{i < j < N} \sum_j^0 \tau_j^i \quad (28)$$

$$a_1 = \sum_{i=1}^N \tau_i^0 H^i \quad (27)$$

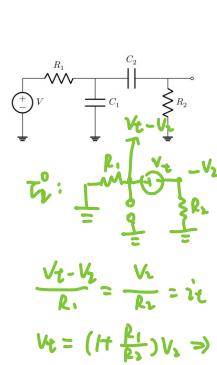
$$a_2 = \sum_{j=1}^{i < j < N} \tau_i^0 \tau_j^i H^{ij} \quad (29)$$

- τ_j^i : the time constant of capacitor j when capacitor i is shorted
- τ_i^0 : cut off all other caps

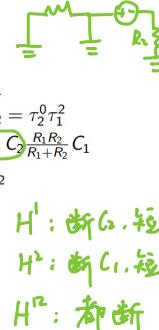
Example



Example



- $\tau_2^1 = R_2 C_2 \rightarrow$
- $\tau_2^2 = (R_1 \parallel R_2) C_1$
- $\tau_1^0 \tau_2^1 = R_1 C_1 R_2 C_2 = \tau_2^0 \tau_2^2$
- $\tau_2^0 \tau_2^2 = (R_1 + R_2) C_2 \frac{R_1 R_2}{R_1 + R_2} C_1$
- $\tau_2^0 = (R_1 + R_2) C_2$
- $\tau_2^1 = (R_1 + R_2) C_1$
- $\tau_2^2 = 0$
- $H^1 = 0$
- $H^2 = \frac{R_2}{R_1 + R_2}$
- $H^{12} = 0$



- $H^1: \text{断 } C_2, \text{ 短 } C_1$
 $H^2: \text{断 } C_1, \text{ 短 } C_2$
 $H^{12}: \text{都断}$

- $H(s) = \frac{a_0 + a_1 s + a_2 s^2}{1 + b_1 s + b_2 s^2}$
- $b_2 = \tau_1^0 \tau_2^1 = \tau_2^0 \tau_1^2$
- $a_2 = \tau_1^0 \tau_2^1 H^{12} = \tau_2^0 \tau_1^2 H^{12}$
- $b_1 = \tau_1^0 + \tau_2^0$
- $a_1 = \tau_1^0 H^1 + \tau_2^0 H^2$

$$H(s) = \frac{R_2 C_2 S}{1 + (R_1 C_1 + R_1 C_2 + R_2 C_2) S + R_1 C_1 R_2 C_2 S^2} \quad (30)$$

二阶的公式